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to safely use products.

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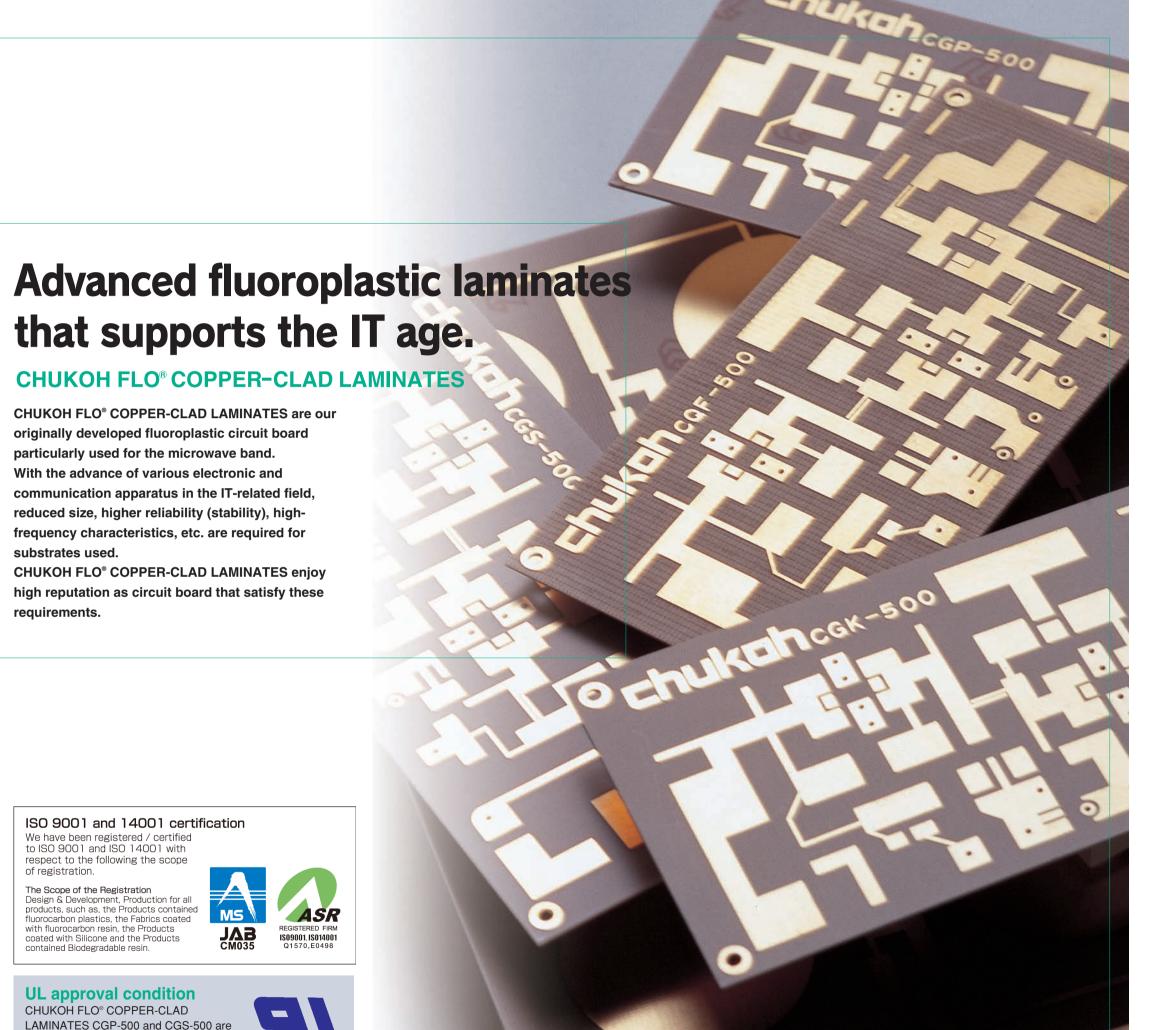
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Primary Features

- •Stable dielectric constant in the wide frequency band.
- Remarkably low dissipation factor in the high frequency band.
- Outstanding tracking resistance.
- Ounrivaled low water absorption in all the substrate materials.
- •Stable characteristics over a wide temperature range (continuous application results: 220°C)

Essential Applications

- Satellite communications Aatellite broadcasting Various mobile telecom capabilities such as advanced mobile phones, etc.
- ●Non-stop automatic electronic toll collection (ETC) system or automatic cruise-assist highway system (AHS) Regional wireless local loop (WLL) networks

 CPU

 Measuring instruments
- Artificial satellite mounted apparatus, etc.

Application example



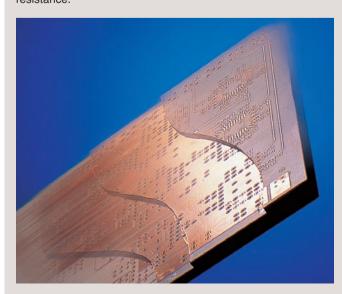
Receiver for satellite communications

Multilayer Substrate

It is possible to form multilayered substrates in order to meet requirements for advanced features and increased densification.

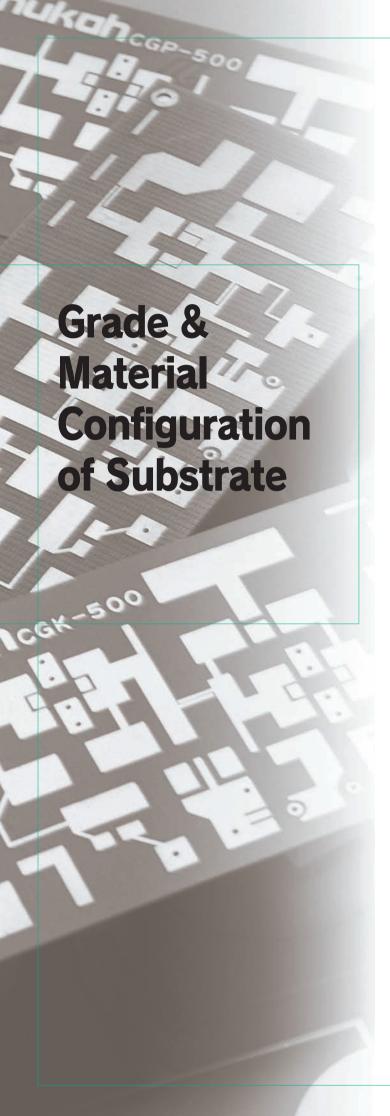
Features of fluoroplastic multilaver board

Higher speed signal processing, small dielectric loss, stable operation, lowering of cross talks, and excellent heat



LAMINATES CGP-500 and CGS-500 are UL-approved products (UL File No. E78936).





Grade

CGP-500

This is standard substrate with superb peel strength, water absorption, through-hole workability, etc. It possesses high dimensional stability and mechanical strength.

CGS-500

This is substrate with still improved dielectric constant and dissipation factor as compared to CGP.

CQF-500

This is substrate with extremely small dielectric loss in the microwave band.

CGN-500

This is substrate with dielectric loss reduced to less than one half and with excellent performance at 20 GHz or higher.

CGA-500

This is substrate intended for mass-production with high-frequency characteristics of fluoroplastic substrate maintained.

CGH-500

Because of dielectric constant equal to general substrates but lower dissipation factor, substrates with lower loss can be obtained by the same design.

CGK-500

The high dielectric constant achieves compact, lightweight, and low-loss high-performance substrates.

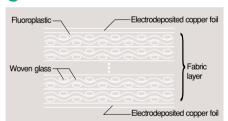
CGC-500

This is substrate that combines strength, dimensional stability, workability, etc., advantages of both conventional ceramics substrate and other high dielectric constant fluoroplastic substrate.

Material Configuration of Substrate

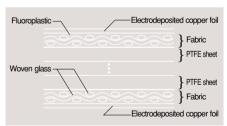
CGP and CGN

Base material: laminate of moven glass impregnated with fluoroplastic.



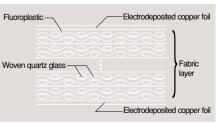
CGS

Base material: laminate of moven glass impregnated with fluoroplastic and fluoroplastic sheet.



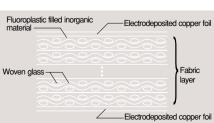
CQF

Base material: laminate of moven quartz glass impregnated with fluoroplastic.



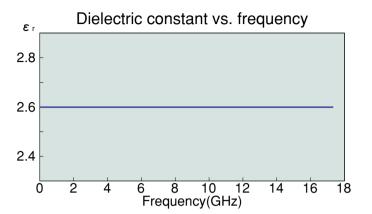
CGA, CGH, CGK and CGC

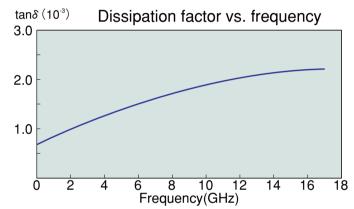
Base material: laminate of moven glass impregnated with fluoroplastic and special inorganic material.



Influence of Frequency on Dielectric Property

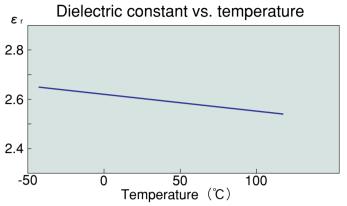
Specimens: CGP-500 (1.6 mm thick with 1/2 oz copper foil on both surfaces) Measurement method: Balanced type disk resonator method Measuring temperature: room temperature (25°C)

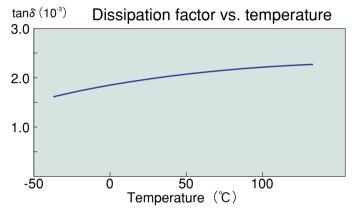




Influence of Temperature on Dielectric Property

Specimens: CGP-500 (0.8 mm thick with 1/2 oz copper foil on both surfaces) Measurement method: Balanced type disk resonator method Measuring frequency: 12 GHz





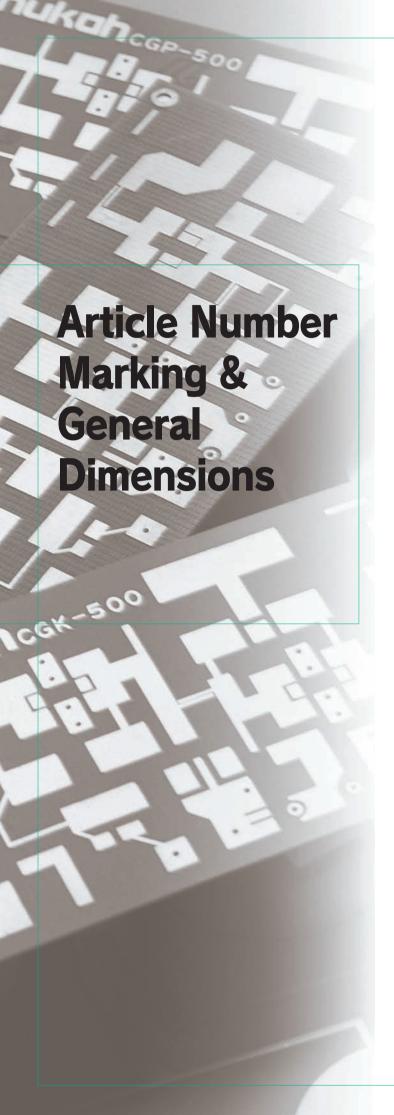
Typical Property table

Property	Unit	Conditions	CGP	CGS	CQF	CGN	CGA	CGH	CGK	CGC	Remarks
Density	_	Α	2.2	2.2	2.2	2.2	2.3	2.3	2.4	3.2	_
Thermal expansion	ppm/°K	-60~150°C	21	40	13	25	20	15	13	30	_
Dool atropath	I/NI /m	Α	3.0	1.0	2.0	1.0	1.5	1.5	1.5	1.0	JIS-C6481
Peel strength	kN/m	Environment of 200°C	1.5	0.5	1.0	0.5	1.0	1.0	1.2	0.5	_
Flexural strength	N/mm²	Α	120	50	60	100	60	120	240	130	
Volume	Volume	Α	1015	1015	10 ¹⁵	10 ¹⁵	1015	1015	10 ¹³	10 ¹³	
resistivity $\Omega \cdot cm$	C-96/40/90	1014	10 ¹⁴	10 ¹⁴	1014	10 ¹⁴	10 ¹⁴	10 ¹³	10 ¹³		
Surface resistivity Ω	0	Α	1014	1014	1014	1014	1014	1014	10 ¹²	10 ¹³	JIS-C6481
	C-96/40/90	1014	10 ¹³	10 ¹³	10 ¹³	1014	1014	1012	10 ¹²		
Insulation	0	Α	10 ¹³	10 ¹³	10 ¹³	1014	10 ¹³	10 ¹³	10 ¹¹	1012	
resistance	esistance Ω	D-2/100	10 ¹³	10 ¹³	10 ⁷	1012	10 ¹⁰	10 ¹²	10 ¹⁰	10 ¹⁰	
Dielectric constant	_	*	2.6	2.15	2.3	2.3	3.0	3.45	5.0	10.0	Diels December method
Dissipation factor	_	*	0.0018	0.0010	0.0005	0.0008	0.003	0.0027	0.004	0.0035	Disk Resonator method
Water absorption	%	_	0.01	0.01	0.04	0.01	0.02	0.02	0.04	0.03	
Chemical resistance	_	_	excellent	JIS-C6481							
Flammability	_	_	incombustible								

 $\label{eq:cgp} \text{$\%$CGP, CGS, CQF, CGN, CGA:12GHz, CGH:9GHz,CGK:8GHz, CGC:6GHz}$

The above values are the measured values in 1.6mm thickness (CGS:0.8mm, CGN:0.6mm, CGA:0.54mm, CGC:4.0mm) and not the specification.

The peel strength is a measured value of 1oz copper foil (35 $\mu\mathrm{m})$



Standard Marking System Chart

(Ex.)

CGP-500 BF-6012

(1)Symbol indicating dielectric substance (2)Symbol indicating dielectric constant (3)Symbol indicating copper foil thickness (4)Symbol indicating the number of copper foil layers

(1)Symbols indicating dielectric substance

Symbol	Dielectric constant band
CGS-500 BP-	2.10~2.25
CGP-500 BF-	2.30~2.85
CQF-500-QP-	2.3
CGN-500 NF-	2.3
CGA-500 HF-	2.9~3.2
CGH-500 XF-	3.25~3.55
CGK-500 XP-	4.5~5.5
CGC-500 JP-	8.5~11.0

(2)Symbol indicating dielectric constant

- •Indicates two decimal places of dielectric constant except CGC.
- •Indicates the first two digits of dielectric constant for CGC only.

(3) Symbol indicating copper foil thickness

Symbol	Kind
0	1/2 oz (18 μm)
1	1 oz (35 μm)
2	2 oz (70 μm)
6	1/3 oz (12 μm)

(4)Symbol indicating the number of copper foil layers

Symbol	Kind
1	One surface clad with electrodeposited copper foil
2	Both surfaces clad with electrodeposited copper foil

Substrate Workability

CHUKOH FLO® COPPER-CLAD LAMINATES can be machined in the same manner as general substrates. The hole wall must have the surface preparation (metallic sodium treatment, etc.) in advance when through-hole machining is carried out.

Typical Dimensions

**unit: mm **Thickness indicates the total thickness of copper-clad laminates

CGP-500

Nominal	Tolerance of thickness			
thickness	1020×1220 · 510×1220	300×300		
0.2	±0.02	±0.02		
0.3	±0.03	±0.03		
0.4	±0.04	±0.03		
0.5	±0.04	±0.03		
0.6	±0.04	±0.03		
0.8	±0.05	±0.04		
1.0	±0.06	±0.04		
1.2	±0.06	±0.04		
1.6	±0.08	±0.04		
2.0	±0.10	±0.05		
2.4	±0.10	±0.05		
3.2	±0.12	±0.06		
4.0	±0.12	±0.06		
<pre>%Tolerance:+5\0</pre>				

CGS-500

Nominal	Tolerance of thickness			
thickness	1020×1220 · 510×1220	300×300		
0.4	±0.05	±0.04		
0.5	±0.05	±0.04		
0.6	±0.06	±0.05		
0.8	±0.08	±0.05		
1.0	±0.10	±0.08		
1.2	±0.12	±0.10		
1.6	±0.20	±0.16		

%Tolerance: +5,0

CQF-500

Nominal	Tolerance of thickness
thickness	300×300
0.4	±0.04
0.5	±0.04
0.6	±0.05
0.8	±0.06
1.0	±0.08
1.2	±0.10
1.6	±0.20

%Tolerance: +5.0

CGN-500

Nominal	Tolerance of thickness
thickness	900×900 · 450×900
0.2	±0.02
0.3	±0.03
0.4	±0.04
0.5	±0.04
0.6	±0.04
0.8	±0.06
1.0	±0.08
1.2	±0.08
1.6	±0.10

[%]Tolerance:+5、0

CGA-500

Nominal thickness	Tolerance of thickness $1020 \times 1220 \cdot 510 \times 1220$
0.4	±0.05
0.5	±0.05
0.6	±0.06
0.8	±0.08
1.0	±0.10
1.2	±0.12
1.6	±0.20

CGH-500

Nominal	Tolerance of thickness
thickness	1020×1220 · 510×1220
0.8	±0.05
1.0	±0.06
1.2	±0.06
1.6	±0.08
2.0	±0.10
2.4	±0.10
3.2	±0.12
4.0	±0.12

[※]Tolerance: +5、0

consult us separately.

●CGK-500

Nominal	Tolerance of thicknes
thickness	300×300
0.3	±0.03
0.4	±0.03
0.5	±0.03
0.6	±0.03
0.8	±0.04
1.0	±0.06
1.2	±0.06
1.6	±0.08
2.0	±0.10
2.4	±0.10

[%]Tolerance:+5、0

CGC-500

Nominal thickness	Tolerance of thicknes	
thickness	900×900 · 450×900	
0.8	±0.08	
1.0	±0.10	
1.2	±0.10	
1.6	±0.12	
%Toloropoo'⊥E 0		

^{*}Tolerance: +5.0

Copper foil is standardly clad on both side with 1/2-oz electrodeposited copper foil. If electrodeposited copper foil of other thickness, one side copper foil, rolled copper foil, and special sizes are required,

1/3oz 0.012mm ± 0.003 Nominal 1/2oz 0.018mm ±0.005 Thickness 1oz | 0.035mm +0.010, -0.005 2oz | 0.070mm +0.018, -0.008 Purity

Dielectric constant substrates and metal base substrates (with aluminum sheets) other than specified are available on request.

99.8% or more